

L-Band Medium & High Power GaAs FET

FEATURES

• High Output Power: P_{1dB}=32.5dBm (Typ.)

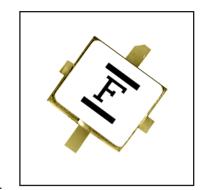
High Gain: G_{1dB}=13.5dB (Typ.)
High PAE: η_{add}=46% (Typ.)

• Hermetic Metal/Ceramic (SMT) Package

• Tape and Reel Available

DESCRIPTION

The FLU17XM is a GaAs FET designed for base station applications in the PCN/PCS frequency range. This is a new product series that uses a surface mount package that has been optimized for high volume cost driven applications.



Fujitsu's stringent Quality Assurance Program assures the highest reliability and consistent performance.

ABSOLUTE MAXIMUM RATINGS (Ambient Temperature Ta=25°C)

Item	Symbol	Condition	Rating	Unit
Drain-Source Voltage	V _{DS}		15	V
Gate-Source Voltage	VGS		-5	V
Total Power Dissipation	PT	Tc = 25°C	7.5	W
Storage Temperature	T _{stg}		-65 to +175	°C
Channel Temperature	T _{ch}		+175	°C

Fujitsu recommends the following conditions for the reliable operation of GaAs FETs:

- 1. The drain source operating voltage ($V_{\mbox{DS}}$) should not exceed 10 volts.
- 2. The forward and reverse gate currents should not exceed 9.6 and -1.0 mA respectively with gate resistance of 200 Ω .
- 3. The operating channel temperature ($T_{\mbox{ch}}$) should not exceed 145°C.

ELECTRICAL CHARACTERISTICS (Ambient Temperature Ta=25°C)

liam	Cymbol	Conditions	Limits			11!4	
Item	Symbol	Conditions	Min.	Тур.	Max.	Unit	
Drain Current	I _{DSS}	$V_{DS} = 5V, V_{GS} = 0V$	-	600	900	mA	
Transconductance	gm	$V_{DS} = 5V, I_{DS} = 400 \text{mA}$	-	300	-	mS	
Pinch-Off Voltage	V_p	$V_{DS} = 5V$, $I_{DS} = 30$ mA	-1.0	-2.0	-3.5	V	
Gate-Source Breakdown Voltage	V_{GSO}	I _{GS} = -30μA	-5	-	-	V	
Output Power at 1 dB G.C.P.	P _{1dB}	V _{DS} = 10V	31.5	32.5	-	dBm	
Power Gain at 1 dB G.C.P.	G _{1dB}	f=2.0 GHz	12.5	13.5	-	dB	
Power Added Efficiency	η_{add}	$I_{DS} = 0.6I_{DSS}$	-	46	-	%	
Thermal Resistance	R _{th}	Channel to Case	-	15	20	°C/W	

Case Style: XM

G.C.P.: Gain Compression Point

Note: The RF parameters are measured on a lot basis by sample testing at an AQL = 0.1%, Level-II inspection. Any lot failure shall be 100% retested.



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POWER DERATING CURVE

Total Power Dissipation (W) 8 6 4 2

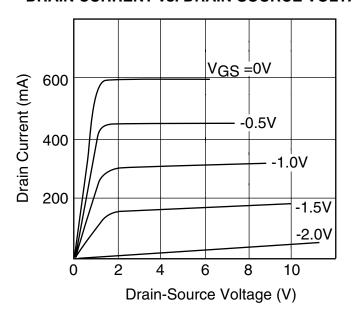
100

Case Temperature (°C)

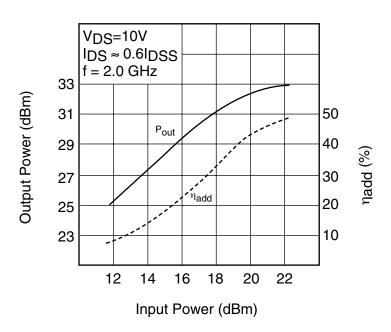
150

200

DRAIN CURRENT vs. DRAIN-SOURCE VOLTAGE



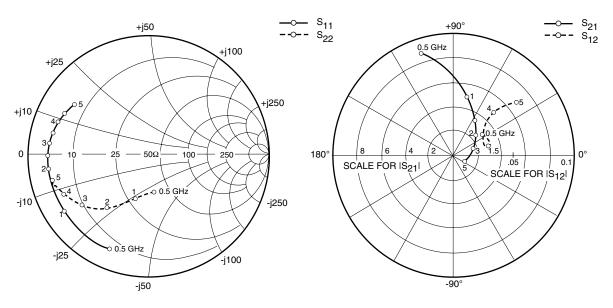
OUTPUT POWER vs. INPUT POWER





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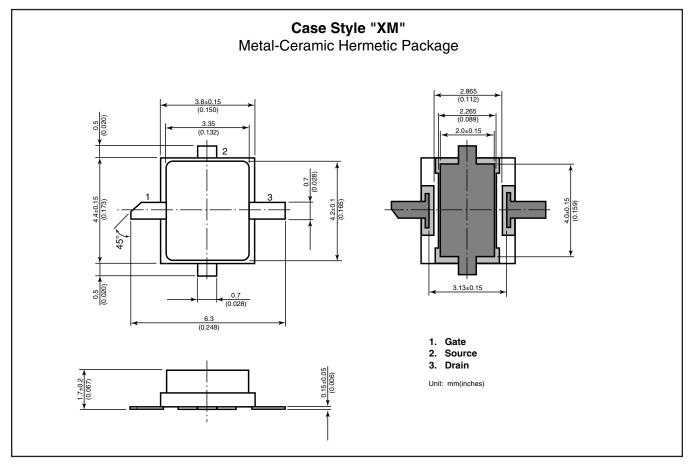
S-PARAMETERS

 $V_{DS} = 10V, I_{DS} = 360 \text{mA}$

FREQUENCY	S	11	S	21	S1	12	S2	2	
(MHZ)	MAG	ANG	MAG	ANG	MAG	ANG	MAG	ANG	
100	.954	-33.9	16.330	160.4	.012	72.2	.335	-18.7	
500	.839	-112.6	8.817	107.9	.028	33.4	.307	-80.7	
1000	.831	-146.9	4.930	78.0	.030	18.4	.378	-106.7	
1500	.824	-162.5	3.299	58.2	.029	16.6	.472	-118.6	
2000	.825	-172.5	2.428	42.0	.027	21.1	.555	-128.3	
2500	.825	179.7	1.912	28.1	.028	35.2	.628	-136.0	
3000	.820	172.6	1.567	15.2	.032	39.3	.682	-143.3	
3500	.809	165.9	1.337	3.3	.038	43.3	.726	-149.3	
4000	.794	159.2	1.183	-8.3	.048	45.0	.761	-155.1	
4500	.775	152.5	1.079	-19.8	.057	43.5	.790	-160.5	
5000	.739	145.5	1.015	-32.1	.067	39.4	.816	-165.9	



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CAUTION

Fujitsu Compound Semiconductor Products contain **gallium arsenide (GaAs)** which can be hazardous to the human body and the environment. For safety, observe the following procedures:

- Do not put these products into the mouth.
- Do not alter the form of this product into a gas, powder, or liquid through burning, crushing, or chemical processing as these by-products are dangerous to the human body if inhaled, ingested, or swallowed.
- Observe government laws and company regulations when discarding this product. This product must be discarded in accordance with methods specified by applicable hazardous waste procedures.

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